## PATENT ABSTRACTS OF JAPAN

(11)Publication number:

11-322846

(43) Date of publication of application: 26.11.1999

(51)int.CI.

C08F. 20/06 CO7C 57/04 CO7C 57/075 C08K 5/20 CO8L 33/02

(21)Application number : 11-064026

(71)Applicant: NIPPON SHOKUBAI CO LTD

(22)Date of filing:

10.03.1999

(72)Inventor: FUJIMARU HIROYOSHI

ISHIZAKI KUNIHIKO HARADA NOBUYUKI NAKAHARA HITOSHI

(30)P riority

Priority number: 10 60060

Priority date: 11.03.1998

Priority country: JP

## (54) HYDROPHILIC RESIN, ABSORPTIVE ARTICLE AND ACRYLIC ACID FOR POLYMERIZATION

(57)Abstract:

PROBLEM TO BE SOLVED: To obtain a hydrophilic resin and an absorptive article having less discoloration and change in color in the case of long-term preservation.

SOLUTION: This hydrophilic resin is obtained by polymerizing a monomer component comprising acrylic acid and ∕or its salt having ≤0.20 ppm total content of hydroquinone and benzoquinone as a main component. This hydrophilic resin comprises an acrylic acid—based polymer as a main component, contains hydroquinone and or benzoquinone and a quinhydrone formation inhibitor in the weight ratio of the inhibitor to the total of hydroquinone and benzoquinone of 10-1,000,000 times. The hydrophilic resin comprises an acrylic acid-based polymer as a main component and has ≤20 degree of pigmentation (YI) after being allowed to stand in an open system under conditions at 70° C at 65%RH for one week.

## **LEGAL STATUS**

[Date of request for examination]

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the examiner's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's decision of rejection]

[Date of requesting appeal against examiner's decision of rejection]
[Date of extinction of right]

Copyright (C); 1998,2003 Japan Patent Office